|    | Type | Hits | Search Text   | DBs             |
|----|------|------|---|-----------------|
| 18 | BRS  | 306  | (((((undercut\$ or (under adj1 cut\$4)) with (etch\$ or rie)) and (photoresist or resist\$4)) and (mask\$4 or hardmask)) and ((polysilicon or (poly adj1 (si or silicon)) or silicon) same (gate or electrode))) and (((438/299-308) or (438/584-596)).CCLS.) | USPAT; US-PGPUB |
| 19 | BRS  | 795  | (isotropic\$ with (etch\$ or rie)) and (photoresist or resist\$4) and (mask\$4 or hardmask) and ((polysilicon or (poly adj1 (si or silicon)) or silicon) same (gate or electrode)) and (((438/299-308) or (438/584-596)).CCLS.)                               | USPAT; US-PGPUB |

|    | Time Stamp          | Comments | Error<br>Definition | Errors |
|----|---------------------|----------|---------------------|--------|
| 18 | 2004/08/16<br>10:39 |          |                     | 0      |
| 19 | 2004/08/16<br>10:38 |          |                     | 0      |